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Evaluation of ferroelectricity in a distorted wurtzite-type structure of Sc-doped LiGaO₂†

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Since the discovery of ferroelectricity in a wurtzite-type structure, this structural type has gathered much attention as a next-generation ferroelectric material due to its high polarization value combined with its high breakdown strength. However, the main targets of wurtzite-type ferroelectrics have been limited thus far to simple nitride/oxide compounds. The investigation of new ferroelectric materials with wurtzite-type structures is important for understanding ferroelectricity in such structures. We therefore focus on β -LiGaO₂ in this study. Although AlN and ZnO possess well-known wurtzite-type structures (*P6₃mc*), β -LiGaO₂ has a distorted wurtzite-type structure (*Pna2₁*), and there are no reports of ferroelectricity in LiGaO₂. In this study, we have revealed that LiGaO₂ exhibits relatively high barrier height energy for polarization switching, however, Sc doping effectively reduces that energy. Then, we conducted thin film preparation and evaluation for Sc-doped LiGaO₂ to observe its ferroelectric properties. We successfully observed ferroelectric behavior by using piezoresponse force microscopy measurements for LiGa_{0.8}Sc_{0.2}O₂/SrRuO₃/(111)SrTiO₃.

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Wurtzite-type ferroelectrics have attracted much attention since the discovery of Sc-doped AlN exhibiting a high polarization value of over 100 $\mu\text{C cm}^{-2}$.¹ The wurtzite-type structure was well known as a pyroelectric material due to its high energy barrier for polarization switching.^{2–4} In this structure, all cations occupy tetrahedral sites and pass through the oxygen-stuffed layer during polarization switching.^{5,6} Ferroelectric behaviors have been reported thus far in Sc-doped AlN,^{1,7} B-doped AlN,^{8,9} Sc-doped GaN,^{10,11} and Mg-doped ZnO.¹² Chemical doping into a wurtzite-type structure reduces the barrier energy of polarization switching, resulting in ferroelectricity. In the case of Sc-doped AlN, the polarization switching barrier energy was calculated as 0.12 eV.¹³ In previous reports, strain effects for Sc-doped AlN,^{14,15} doping level dependence in Sc-doped AlN¹⁶ and ferroelectricity predictions of other new wurtzite-type material such as LaN,¹⁷ Mg₂XN₃ (X = Sb, Ta and Nb)¹⁸ and other complex

materials¹⁹ are demonstrated by using first-principles calculations. Although wurtzite-type ferroelectric materials are candidates for next-generation ferroelectric materials, ferroelectric observations in such structures have been limited to simple oxides/nitrides with chemical doping due to the relatively high barrier energy for polarization switching.²⁰ The limited selectivity of doping elements is attributed to the composition of simple oxides/nitrides, which consist of divalent/trivalent cations. In addition, there are limited options for new simple oxides/nitrides to be considered as ferroelectric materials.^{4,17–19} Therefore, we have tried to investigate complex oxide materials with wurtzite-type related structures.

We focus on β -LiGaO₂, which exhibits a distorted wurtzite-type structure. The crystal structure of β -LiGaO₂ falls within the orthorhombic system with a space group of *Pna2₁*, and spontaneous polarization takes place along the *c*-axis.^{21,22} A single crystal growth of β -LiGaO₂ was reported to serve as a substrate on which to deposit GaN thin films.^{23,24} Due to the difference in ionic radii between Li⁺ and Ga³⁺,²⁵ the tetrahedra are distorted compared to those in the wurtzite-type structure. Moreover, the selectivity in doping elements is improved because of the presence of monovalent and trivalent cations in the structure. NaGaO₂, AgGaO₂, and CuGaO₂ are reported to possess the same structure as β -LiGaO₂.^{26–28} However, it is difficult to treat NaGaO₂ in air due to its high deliquescence. Besides, the synthesis of AgGaO₂ and CuGaO₂ requires NaGaO₂ as a starting material. Therefore, we decided to investigate the ferroelectricity in β -LiGaO₂. In this study, we carried out first-

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principles calculation and thin film preparation to evaluate a polarization switching of LiGaO₂ system. First, we revealed that non-doped LiGaO₂ showed relatively high barrier height energy for the polarization switching. Then, we carried out calculation to evaluate the effect of Ga-site substitution on LiGaO₂. The results suggested that Sc-doping effectively reduces that energy. Finally, we prepared Sc-doped LiGaO₂ epitaxial thin films and uncovered the probability of ferroelectricity using piezoresponse force microscopy (PFM).

We carried out density functional theory (DFT) calculations using the projector augmented wave (PAW) method²⁹ as implemented in the VASP^{30,31} for structural optimizations. We utilized the modified Perdew–Burke–Ernzerhof generalized gradient approximation (PBEsol-GGA)³² as the exchange–correlation functional in our calculations. The *k*-point mesh was $8 \times 8 \times 8$. The cutoff energy and convergence energy were 550 eV and 1.0×10^{-7} eV, respectively. Born effective charges were calculated using density functional perturbation theory (DFPT). The spontaneous polarization value was estimated as the product of Born effective charges and atomic displacements. The calculated crystal structure is depicted by using VESTA software.³³

All thin films were fabricated *via* a pulsed laser deposition method with a fourth harmonic wavelength of Nd:YAG. First, we prepared a ceramics target of Li(Ga_{1-x}Sc_x)O₂ ($x = 0, 0.05, 0.15, 0.20$). The starting materials of Li₂CO₃, Ga₂O₃, and Sc₂O₃ were weighed through stoichiometry and well ground with an agate pestle and mortar. The powder was calcined at 740 °C for 12 h. After the calcination, the powder was pelletized by using a cold isostatic press of 200 MPa, and the prepared pellets were sintered at 1100 °C for 2 h. We then deposited LiGaO₂ film onto (111)SrTiO₃ using the sintered target. The deposition conditions were a substrate temperature of 500 °C and an oxygen partial pressure of 10 mTorr. The crystal structure of prepared thin films was evaluated using HR-XRD (Smartlab, Rigaku). For the evaluation of ferroelectricity, a conductive SrRuO₃ was deposited as a bottom electrode. The SrRuO₃ film was deposited at the substrate temperature of 650 °C and oxygen partial pressure of 50 mTorr. The ferroelectricity of the prepared films was evaluated using PFM (MFP-3D, Asylum Research).

The crystal structure of β-LiGaO₂ (*Pna2*₁) is shown in Fig. 1a. Using this polar structure as the reference, we created an intermediate structure representing polarization switching,

where all cations moved in the [00–1] direction and occupied five-coordinate sites.^{3,14,16} Fig. 1b and c show the crystal structures of the polar and intermediate states, respectively, after the structural optimization. The difference in final energy per formula unit between the polar and intermediate structures is 0.64 eV per f.u. This value is quite high compared with the 0.35 eV per f.u. in the Sc-doped AlN cases,¹³ indicating that it is hard to observe ferroelectricity in non-doped LiGaO₂. We then focused on Ga³⁺ site substitution by trivalent cations (Al³⁺, B³⁺, Sc³⁺). These three elements were selected in a viewpoint of ionic radii. The calculated unit cell has four Ga³⁺ sites. Replacing one Ga³⁺ site corresponds to a 25% doping level. The calculated structures with 25% Ga replaced LiGaO₂ by Al, B, and Sc are shown in Fig. S1.† The barrier height energies of Al-, B-, and Sc-doped LiGaO₂ are 0.55, 1.84, and 0.21 eV per f.u., respectively. These results suggest that Sc doping is particularly effective at reducing the barrier height energy for polarization switching.

We investigated the dependence of the Sc amount in the LiGaO₂ structure by using first-principles calculations. The crystal parameters after the structural optimization with Sc-doped LiGaO₂ (Sc-doped level: 0%, 25%, 50%, 75%, and 100%) are shown in Table 1, as are the average *u*-parameters. The *u*-parameter is the position of a cation-stuffed plane relative to an anion-stuffed plane along the polarization axis (*c*-axis) of a wurtzite-type structure. In a simple wurtzite-type structure, the structure is polar when the *u*-parameter is less than 0.5. In the case of a complex oxide with a wurtzite-type structure, there are more than two kinds of cations; thus, the cation-stuffed plane is not flat. We then evaluated the average *u*-parameters calculated for each cation site. The calculation results suggest that the *u*-parameters of the non-doped and 25% Sc-doped LiGaO₂ are less than 0.5. On the other hand, the *u*-parameters remain stable at 0.5 with Sc contents exceeding 50% in Sc-doped LiGaO₂. This

Table 1 Lattice parameters of calculated Sc-doped LiGaO₂ structures

	Sc0%	Sc25%	Sc50%	Sc75%	Sc100%
<i>a</i> (Å)	5.394	5.509	5.922	6.022	6.131
<i>b</i> (Å)	6.373	6.444	6.962	7.044	7.104
<i>c</i> (Å)	5.022	5.007	4.171	4.184	4.196
<i>u</i> (a.u.)	0.382	0.386	0.5	0.5	0.5

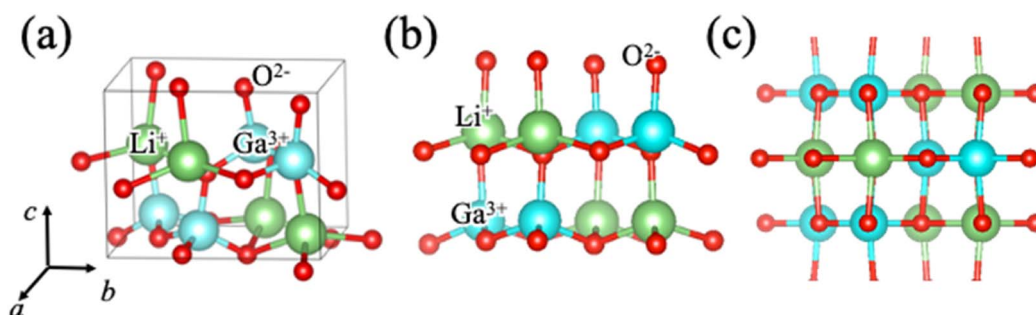


Fig. 1 (a) Schematic illustration of LiGaO₂ crystal structure. (b) The initial state of polarization switching and (c) the intermediate state of polarization switching in LiGaO₂.

result is attributed to the intermediate state of the polarization switching being more stable than the polar state. This result indicates that the intermediate state became stable as the Sc content increased in Sc-doped LiGaO₂. The same phenomenon was reported in Sc-doped AlN, where 50% Sc-doped AlN shows almost zero polarization value.¹⁴ Besides, the *c*-axis length decreased with increasing Sc content in Sc-doped LiGaO₂. The polarization values calculated by using the DFPT method are 91.4 $\mu\text{C cm}^{-2}$ (non-doped LiGaO₂) and 86.1 $\mu\text{C cm}^{-2}$ (LiGa_{0.75}Sc_{0.25}O₂). The predicted polarization value is comparable to that in 90.0 $\mu\text{C cm}^{-2}$ for ZnO,⁵ and 90.6 $\mu\text{C cm}^{-2}$ for Mg₂NbN₃.¹⁸ Then, we have tried to prepare LiGaO₂ epitaxial thin films *via* a pulsed laser deposition method.

Fig. 2a shows the out-of-plane XRD results for the prepared thin films. β -LiGaO₂ (*Pna*₂₁) 002 and 004 peaks were observed along the SrTiO₃[111] without any impurity peaks. This result indicates that the β -LiGaO₂ (*Pna*₂₁)-oriented film is grown on the (111)SrTiO₃ substrate along the *c*-axis. Fig. 2b shows the results of phi-scan measurements on LiGaO₂ 011 and SrTiO₃ 110 to examine the crystal structure in the in-plane direction. Although a three-fold rotation symmetry is observed in SrTiO₃ 110, a six-fold rotation is observed in LiGaO₂ 011 with a 30° peak shift from the SrTiO₃ 110 peaks. These results indicate that the in-plane relationship is LiGaO₂[010]/SrTiO₃[10–1], and the observed six-fold rotation symmetry of LiGaO₂ 011 appears to have originated from the three-fold rotation of (111)SrTiO₃. The result of 2D reciprocal space mapping of prepared LiGaO₂/(111)SrTiO₃ thin film is shown in Fig. S2.† The relationship of crystal orientation between (001)LiGaO₂ and (111)SrTiO₃ was depicted in Fig. S3.† Along SrTiO₃ [10–1] direction, LiGaO₂ is well matched with a lattice mismatch of 2.7%. The relationship of LiGaO₂/(111)SrTiO₃ is in good agreement with that of ZnO/(111)SrTiO₃,³⁴ although the space groups of ZnO is different with that of LiGaO₂ whereas the atomic alignment is same. These results indicated that (001)LiGaO₂/(111)SrTiO₃ epitaxial thin films were obtained. For electric measurements, LiGaO₂/SrRuO₃/(111)SrTiO₃ thin films were prepared by using SrRuO₃ as a bottom electrode. However, no ferroelectric behavior was observed *via* PFM (Fig. S4†) and *P*-*E* hysteresis measurements due to the relatively high barrier height

energy of polarization switching in non-doped LiGaO₂. Therefore, we focused on Sc doping to Ga³⁺ sites in LiGaO₂.

Li(Ga_{1-x}Sc_x)O₂ (*x* = 0.05, 0.15, 0.20) ceramics targets were sintered by a conventional solid state reaction to prepare Sc-doped LiGaO₂ thin films. The XRD results of the prepared thin films are shown in Fig. 3a. LiGaO₂ 002 and SrRuO₃ 111/*c*/222_c peaks are observed along the out-of-plane direction, the same as in the non-doped LiGaO₂ epitaxial thin film. The *c*-axis length calculated from the out-of-plane XRD results are plotted in Fig. 3b. The calculated *c*-axis value is also shown in Fig. 3b. The *c*-axis length monotonically decreased as Sc content increased in Sc-doped LiGaO₂, indicating that Sc-doped LiGaO₂ epitaxial thin films were obtained. The result also suggests that the solution limit of Sc into LiGaO₂ epitaxial thin film is above 20%.

Finally, PFM results of LiGa_{0.8}Sc_{0.2}O₂/SrRuO₃/(111)SrTiO₃ are shown in Fig. 4a. We can clearly see a ferroelectric butterfly-shape curve of the amplitude signal and a 180° phase hysteresis curve. Additional PFM results measured in several points are shown in Fig. S5.† The result of non-doped LiGaO₂ epitaxial thin film is also shown in Fig. S4,† in which no ferroelectric behavior is observed. The results of written PFM images of phase and amplitude shown in Fig. 4b, which reflects a pre-imposed voltage before measurements. These findings suggest that the prepared thin film exhibits the potential for ferroelectric behavior. The frequency dependence of dielectric constant and dielectric loss of prepared sample is shown in Fig. S6.† The dielectric loss is less than 0.1 at 1 kHz. Unfortunately, we could not see a hysteresis loop in the *P*-*E* measurements because the prepared films were leaky during measurements applying high voltage. In our future studies, we intend to enhance the thin film quality by optimizing growth conditions. This will enable us to observe a *P*-*E* hysteresis loop, facilitating a direct evaluation of ferroelectricity in Sc-doped LiGaO₂.

We investigated ferroelectricity in LiGaO₂ by using calculation and preparation/evaluation of epitaxial thin films. We carried out first-principles calculations by using the VASP code for LiGaO₂ and Sc-doped LiGaO₂. The calculated results suggested that Sc doping reduces the barrier height energy of polarization switching in Sc-doped LiGaO₂. Then, we have

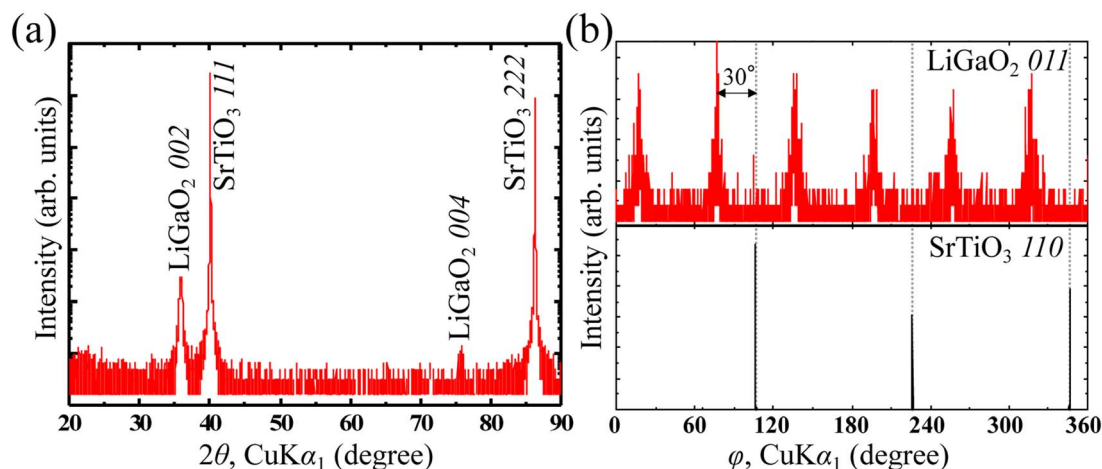


Fig. 2 (a) Out-of-plane XRD profiles of LiGaO₂/(111)SrTiO₃. (b) Phi-scan XRD patterns of LiGaO₂ 011 and SrTiO₃ 110.



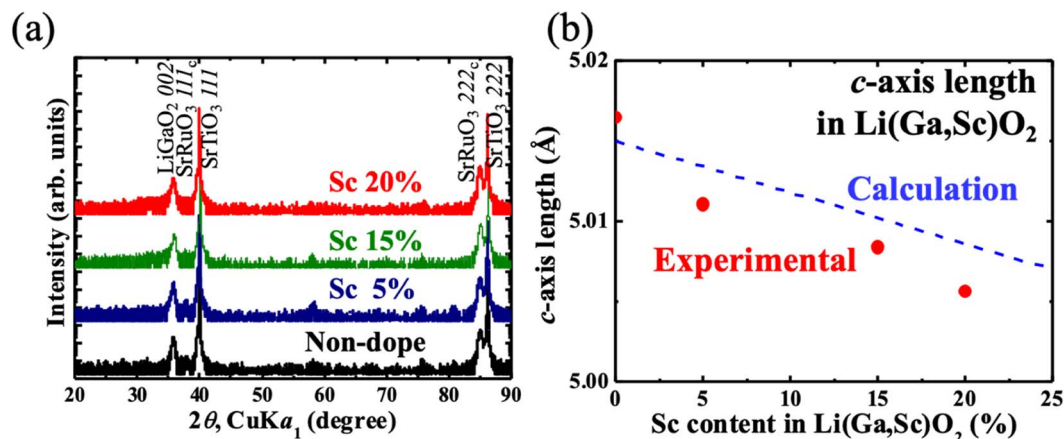


Fig. 3 (a) Out-of-plane XRD profiles of LiGa_{1-x}Sc_xO₂/(111)SrTiO₃ ($x = 0, 0.05, 0.15, 0.20$). (b) The c -axis lengths of prepared thin films with calculated values (blue dashed line).

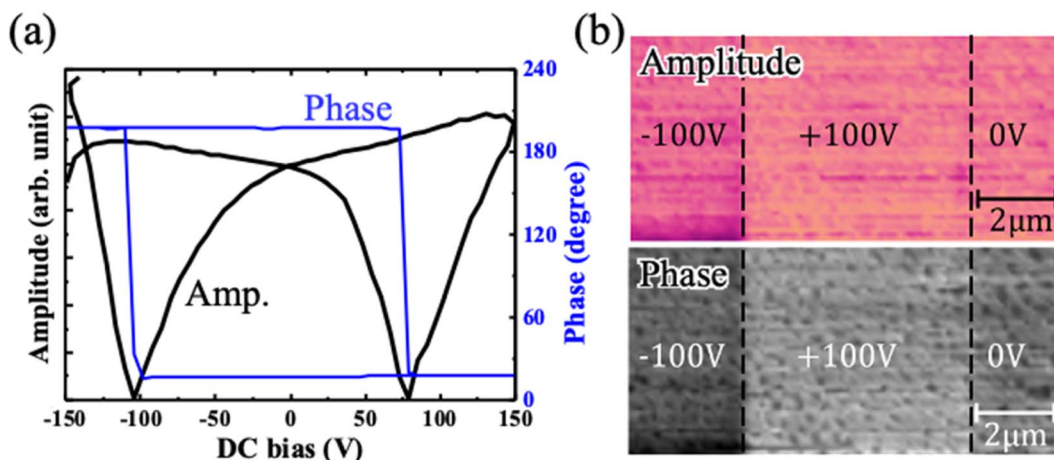


Fig. 4 (a) PFM results of amplitude (black line) and phase (blue line) signals in LiGa_{0.8}Sc_{0.2}O₂/SrRuO₃/(111)SrTiO₃. (b) PFM images of amplitude and phase for written sample in LiGa_{0.8}Sc_{0.2}O₂/SrRuO₃/(111)SrTiO₃.

started to prepare LiGaO₂ epitaxial thin film, and revealed that LiGaO₂ was epitaxially grown on a (111)SrTiO₃ substrate by a pulsed laser deposition method. The growth relationships between LiGaO₂ ($Pna2_1$) and the SrTiO₃ substrate are follows: (001)LiGaO₂/(111)SrTiO₃ and (010)LiGaO₂/(10-1)SrTiO₃. In this study, the pure LiGaO₂ does not show any ferroelectric behavior by using P - E measurements and PFM. We then prepared Sc-doped LiGaO₂ epitaxial thin films. We successfully observed ferroelectric behavior *via* PFM measurement for LiGa_{0.8}Sc_{0.2}O₂/SrRuO₃/(111)SrTiO₃.

Conflicts of interest

There are no conflicts to declare.

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